

Effect of Ethane-1,2-Diamine on Growth of ZnO Nanorods and Cyclohexane Sensing by Current-Voltage Characteristics Investigations

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Keywords: Vertically Aligned ZnO Nanorods, Ethane-1,2-diamine, Chemical Bath Deposition, IV characteristics, Cyclohexane.

Abstract. The growth of vertically aligned ZnO Nanorods arrays using Zinc Nitrate hexahydrate and Hexamethylene Tetramine (HMTA), by Chemical Bath Deposition on Silicon Wafer was investigated. The growth was conducted under influence of Ethane-1,2-diamine, the amine based enhancer in three different ratios (1:0.5, 1:1, 1:1.5). The effect different ratios of enhancers on morphology and aspect ratio by Scanning electron microscope (SEM) and crystallinity of the as grown nanorods by X-ray powder diffraction (XRD). Electrical Properties such as current–voltage characteristics were investigated, its correlation to the morphology and aspect ratio of the nanorods in the presence of 100µL-500µL of Aromatic Compound Cyclohexane and at different applied voltages.

Introduction

Zinc Oxide (ZnO) is a versatile functional direct band gap of 3.37eV and a large binding energy. 1D ZnO nanostructures such as nanotubes [1], nanowires [2], nanorods [3], nanobelts [4], tetrapods [5] and nanoribbons [6] stimulate considerable interests for scientific research due to their importance in fundamental physics studies and their potential applications in various fields. There are many synthesis routes for ZnO Nanorods and include Chemical bath deposition [7] hydrothermal method [8], Vapor-phase transport [9] Pulsed laser deposition [10]. Solution based synthesis method offers the distinct advantage of being low cost and can be performed at temperatures less than 100°C and most importantly the process formulated is easily implemented [11].

The growth of ZnO Nanorods is carried out in the presence of hexamethylenetetramine (HMTA), which promotes axial growth in the media, there are studies being performed to evaluate and better understand the effect of precursors in the growth of ZnO Nanorods [12,13]. Along with HMTA, other enhancers have also been studied, which have a pronounced effect on the growth of ZnO Nanorods [14]. It has been observed that flowerlike structures are formed, when HMTA is used for thermolysis of a zinc complex with Ethane-1,2-diamine [15]. The effect of HMTA has been observed in all these papers and more, effect of temperature and time has been realised as an important parameter for the growth of vertically aligned Nanorods and papers detailing and evaluating the effect of temperature and time can be found in literature [16,17]. HMTA has been realised as to be the driving force for 1 dimensional growth in ZnO nanorods chemical synthesis routes. It can be referred as driving force with studies detailing the effect of equimolar and non-equimolar concentration effects of HMTA can be found in Literature [18-20]. This serves as motivation for the study, as to amine group based compound will affect the growth of ZnO Nanorods, while all other conditions like time, temperature, concentration of precursor is kept the same. For this purpose, Ethane 1-2 Diamine is taken into consideration. The effect in three different ratios of precursor (Zinc Nitrate and HMTA) to the enhancer (Ethane 1-2 Diamine), the ratios 1:0.5, 1:1, 1:1.5 were studied.

Experimental Section

Synthesis of ZnO Seed Layer. The Synthesis of the ZnO Nanorods is done by following two steps, depositing seed layer and growth on the seeded silicon (100) wafer substrate. The substrates were pre-cleaned in water, acetone and ethanol (30 minutes each) by using bath sonicator, before deposition of seed layer. The Seed layer was coated by using spin coating 10 μ L of ZnO seed solution (5mM Zinc Acetate in Absolute Ethanol), the wafer was spun at 3000 RPM for 20 seconds. The Substrates were annealed at 350°C for 20 minutes. (Fig. 1)

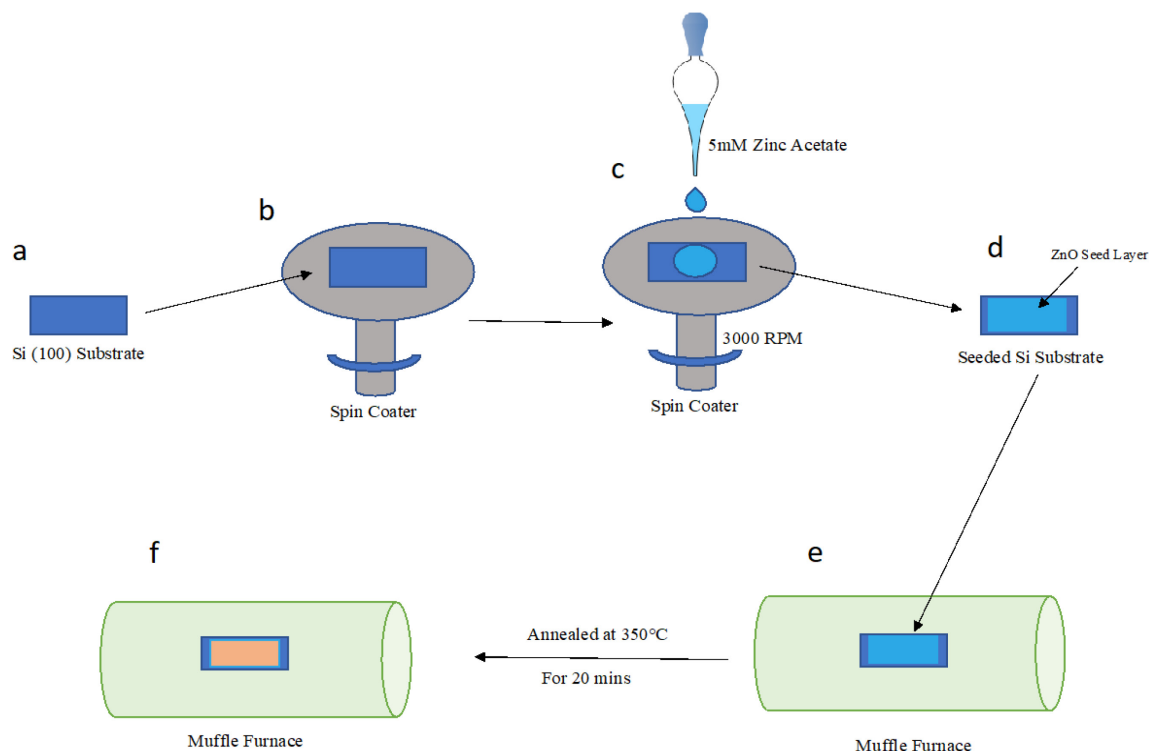


Fig. 1. The process flow for seed layer formation. a) Pre-cleaned Silicon (100) Substrate, b) the Si wafer placed on Spin coater stage with 3000 RPM parameters setting, c) 10 μ L of 5mM Zinc Acetate (seeding sol) was dropped on the substrate via micropipette, d) the substrate was allowed to dry in air, e) the sample was placed in muffle furnace and annealed at 350°C for 20 mins, and f) ZnO seed layer deposited substrate

Synthesis of ZnO Nanorods. ZnO nanorods were grown using chemical bath deposition, the bath comprises precursors, 0.025M (or 25mM) Zinc Nitrate (ZnNO_3) and 0.025M (or 25mM) HexamethyleneTetramine (HMTA). In Addition to these precursors the bath solution contains, amine group based enhancer Ethane-1,2-diamine. The enhancer was evaluated based on three different ratios of precursor (Zinc Nitrate and HMTA) to the enhancer, the ratios were 1:0.5, 1:1, 1:1.5 (Zinc Nitrate/HMTA: Enhancer). The seeded substrate was placed in the bath vertically via clamp and the bath was heated to 90°C for one hour. The substrate was then further heat treated at 450°C for 1 hour. (Fig. 2).

Characterization

The prepared samples were characterized by using Scanning Electron Microscopy (SEM) (JEOL-JSM- 6490LA) with operating voltage of 10-20 kV, spot size of 35-60, and working distance of 10mm and X-Ray Diffractions (XRD) (STOE diffractometer) in 2 θ range of 20-50 degrees was performed to determine the crystalline nature of ZnO Nanorods.

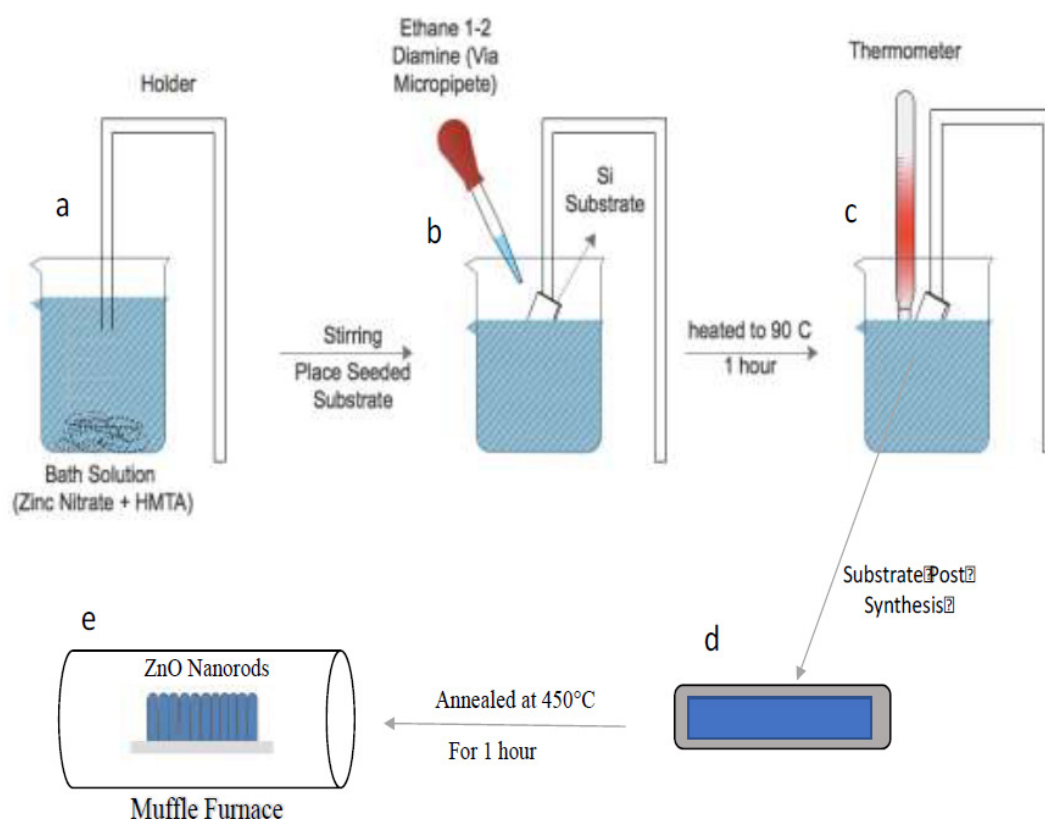


Fig. 2. Synthesis Route for ZnO Nanorods. a) Bath Solution was prepared (25mM of Zinc Nitrate and HMTA), b) Seeded Substrate was placed vertically in the bath and Ethane 1-2 Diamine was added to the bath solution in different ratios, c) the solution was heated to 90°C for one hour, d) the substrate was removed from the bath and cleaned with water and ethanol, and e) the substrate was annealed at 450°C for 1 hour

I-V Characteristic Investigations (Cyclohexane Sensing). Samples prepared at different ratios were characterized using Electrochemical Workstation (VSP EC-Lab). By this equipment I-V characteristics of these samples were calculated. For Investigation of IV characteristics, Contacts were made using quick drying silver paste. The Cyclohexane concentration was varied between 100, 200, 300, 400 and 500 μL . The substrate acts as an electrode and is dipped in water to which the cyclohexane is added in varying concentration. The system assembly is as shown in Fig. 3.

Results and Discussion

Fig. 4 represent the surface morphology of the as grown Nanorods in various ratios and it can be observed via the SEM images that addition of Ethane 1-2 Diamine, to the bath containing Zinc Nitrate and HMTA, the rods formed have pointed ends, and as ratio is increased the structures become more pointed and lesser is diameter. When the ratio of Ethane 1-2 Diamine is low (Fig. 4a), the rods formed are branched together, few placed horizontally and few vertically aligned. In case of ratio 1:1 (Fig. 4b) the surface coverage observed on the substrate is better as compared to ratio 1:0.5 (low), and it is observed that the diameter of the grown rods has further decreased, with all the rods vertically aligned. At increased ratio (Fig. 4c, ratio 1.5) the rods grown observed have angled rather than vertical alignment observed at ratio 1. At EDA ratio 0.5 the diameter $\sim 250\text{nm}$, but at ratio 1 and 1.5 the average diameter is approximately $\sim 130\text{ nm}$ and 90nm respectively.

As such with increasing the ratio of EDA average diameter and length of the grown 1D structures is affected i.e. decreases. In earlier studies the effect of precursor solution was evaluated on basis of dielectric constant of the solution, with the decrease in dielectric constant the solubility of the inorganic salt decreases as well. With addition of precursors like Ethane 1-2 Diamine, the dielectric constant of the solution changes, which results in changes observed in the morphology as shown in SEM images.

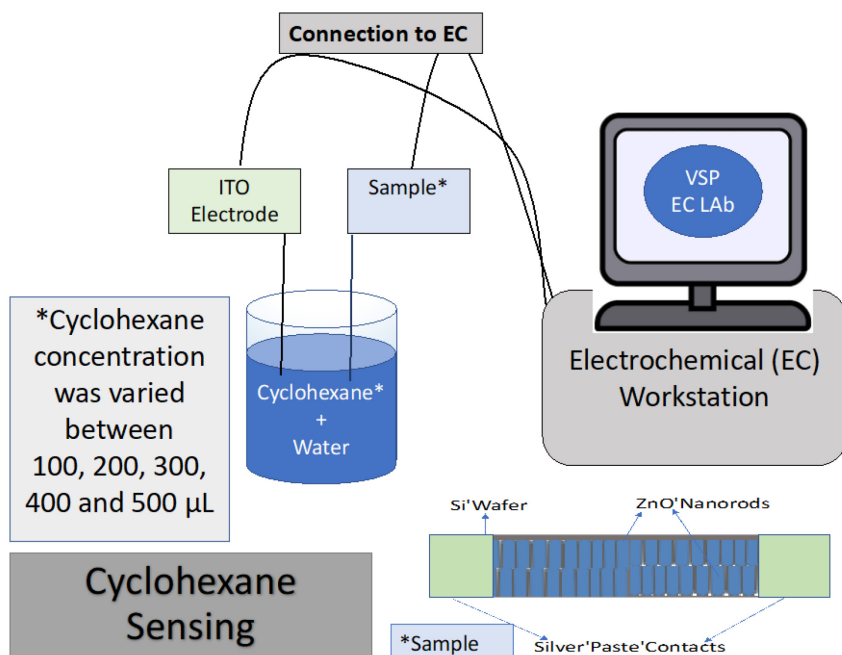


Fig. 3. Schematic of IV Characteristics Investigations

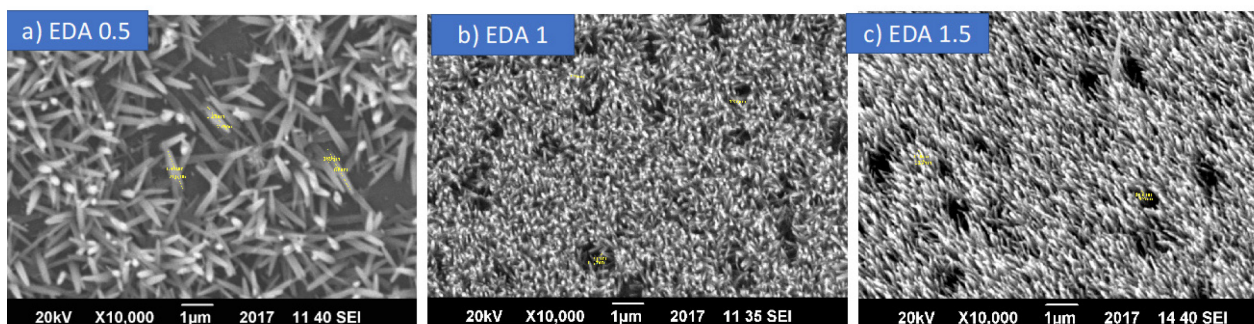


Fig. 4. SEM images of ZnO Nanorods. (Zinc Nitrate/HMTA: EDA [Ethane 1-2 Diamine]) a) 1:0.5 Ratio 25mM Zinc Nitrate, HMTA and 12.5mM EDA), b) 1:1 ratio (25mM Zinc Nitrate, HMTA and EDA) and, c) 1:1.5 (25mM Zinc Nitrate, HMTA and 37.5mM EDA)

Fig. 5(a) shows the XRD pattern observed. The XRD Pattern evidences in favor of ZnO Nanorods formed (JCPDF file 211486, 030888). The XRD confirms the hexagonal Wurtzite structure of ZnO Nanostructures formed, single sharp peak corresponding to plane (002) show successful c-axis growth. Few small peaks not corresponding to the ZnO wurtzite structure are due to presence of Zinc Silicate which is formed when the heat treatment of seed layer is done as it contains ZnO coated sol over Silicon wafer, the peak is observed because of some uncovered area. The peak shifts towards increasing angles in confirmation to the more pointed ends (needles like end) being formed as successive ratios are increased.

Fig. 5 (b, c, d) show the results observed for changes observed in IV characteristics of the samples with addition of cyclohexane. A trend of decreasing current is observed when the concentration of cyclohexane is increased, the cyclohexane mixed with water causes a change in electrochemical environment of the placed substrate. The change in environment around the dipped substrate manifests in form of decreased current observed. At 1:0.5 ratio (Fig. 5b) the early results with 100 to 200µL and then to 300µL concentration a uniform decrease is observed but at increased concentrations the effect is not that prominent and the decrease becomes small. In case of 1 ratio (Fig. 5c), the difference between current observed from 100 to 200µL is very prominent, but after that the increasing concentration shows negligible changes in current. While for 1.5 ratio of EDA (Fig. 5d) depicts a uniform decrease in current for concentrations 100 to 500µL. In case of non-coated samples, i.e. Silicon substrate as it is, the test results show an insulating behavior.

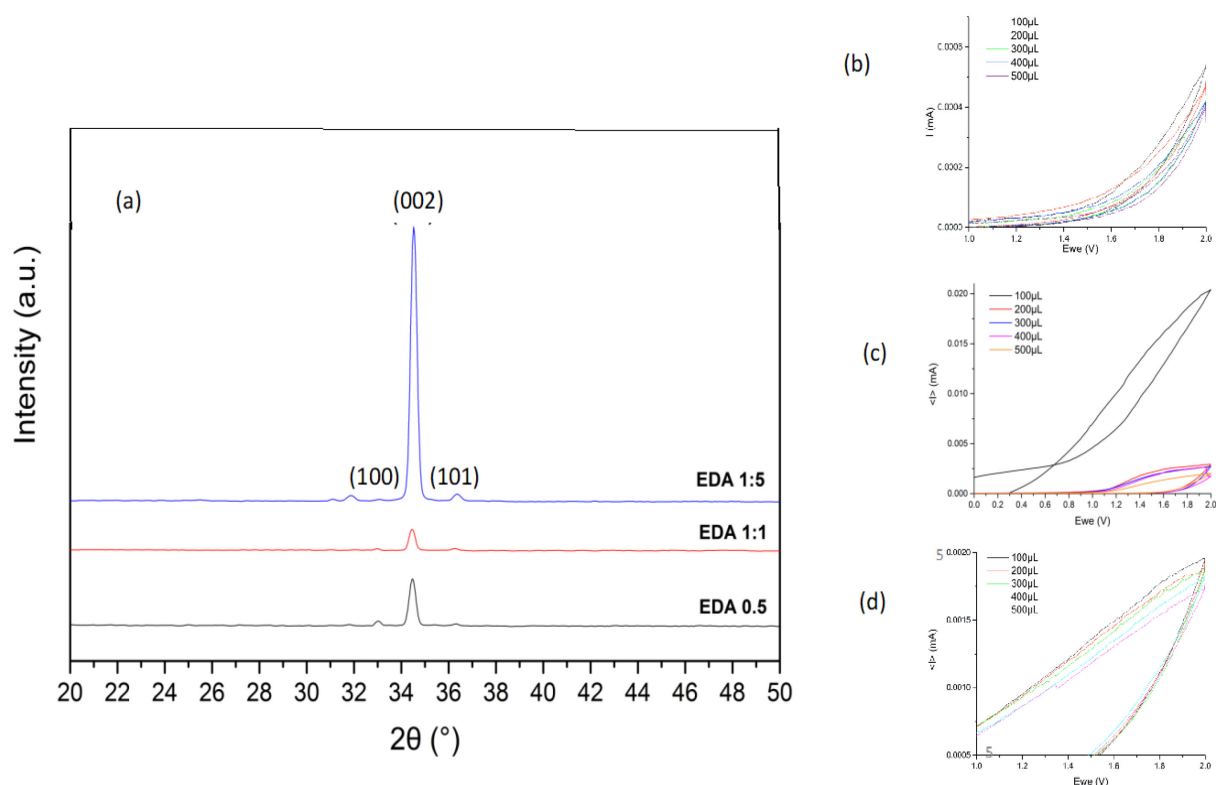


Fig. 5. (a) XRD Pattern observed for ZnO nanorods. (b) IV characteristics 1:0.5 Ratio, c) IV characteristics 1:1 ratio and, d) IV characteristics 1:1.5 in presence of 100 μ L-500 μ L cyclohexane

Conclusions

Growth of ZnO nanostructures showing different morphology with the addition of Ethane 1-2 Diamine. It can be observed in the SEM images, that with all other variables as constant, addition of EDA in various concentration affecting the system. The length and diameter of the as grown nanorods is different for three ratios, (Fig. 4.). Hence it can be hypothesized that the aspect ratio of the nanorods grown is affected by addition of Ethane 1-2 Diamine. The XRD plots is used to confirm that the samples produced are single crystalline as depicted by one sharp peak (002). The as grown rods show different IV characteristics in presence of cyclohexane, with the 1:5 ratio rods showing a systematic decrease in current values with addition of Cyclohexane, showcasing its potential as a sensing material.

Acknowledgements

We would also like to thank Shayan Naveed, Ramsha Khan and Adeel Riaz for useful discussions. Special mentions for Lab Tech. Shams Ud Din and Lab Tech. Khurram Shahzad for assistance in obtaining SEM and XRD data.

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